External_Type	Material_Group	Substances	CAS_Number	Mass	Mass_Percentage_in_Leaf	Massmg
Die	Doped silicon	Silicon (Si)	7440-21-3	0.42366	100.0	6.1
			Subtotal	0.42366	100	6.1
Wire	Pure metal	Aluminium (Al)	7429-90-5	0.15835	100.0	2.28
			Subtotal	0.15835	100	2.28
Post-plating	Pure Metal	Tin (Sn)	7440-31-5	1.73632	100.0	25
			Subtotal	1.73632	100	25
Lead Frame	Copper alloy	Phosphorous (P)	7723-14-0	0.02334	0.04	0.336
	Copper alloy	Iron (Fe)	7439-89-6	0.05834	0.1	0.84
	Copper alloy	Copper (Cu)	7440-50-8	58.25858	99.86	838.824
			Subtotal	58.34026	100	840
Mould Compound	Polymer	Phenol Formaldehyde resin (generic)	9003-35-4	3.39884	8.7	48.9375
	Polymer	Epichlorohydrin/Diethyleneglycol Epoxy resin (generic)	25928-94-3	6.25074	16.0	90
	Filler	Silica fused	60676-86-0	29.30035	75.0	421.875
	Carbon Black	Carbon black	1333-86-4	0.1172	0.3	1.6875
			Subtotal	39.06713	100	562.5
Die Attach	Lead alloy	Tin (Sn)	7440-31-5	0.0132	5.0	0.19
	Lead alloy	Silver (Ag)	7440-22-4	0.0066	2.5	0.095
	Lead alloy	Lead (Pb)	7439-92-1	0.24413	92.5	3.515
			Subtotal	0.26393	100	3.8
Wire	Pure metal	Aluminium (Al)	7429-90-5	0.01036	100.0	0.1491
			Subtotal	0.01036	100	0.1491
			Total	100.00001	100	1439.8291

## Disclaimer

All information in this document is furnished for exploratory or indicative purposes only. All information in this document is believed to be accurate and reliable. However, WeEn Semiconductors does not give any representations or warranties as to the accuracy or completeness of such information and shall have no liability for the consequences of use of such information. WeEn Semiconductors may make changes to information published in this document at any time and without notice. Minor deviations may occur in the products from different manufacturing location. This document supersedes and replaces all information supplied prior to the publication hereof. Nothing in this document may be interpreted or construed as an offer to sell products that is open for acceptance or the grant, conveyance or implication of any license under any copyrights, patents or other industrial or intellectual property rights.